Application No. 09/735,566 Am'ndt Dated: May 12, 2003

Reply to Office Action of February 12, 2003

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Atakov, et al.

Docket: 200308123-4

Application No.:

Examiner: TUGBANG, Anthony D.

(Continuation of Application No.: 09/735,566

Art Unit:

3729

For:

A Method of Forming Electrical Interconnects

Having Electromigration-Inhibiting Plugs (Amended)

Mail Stop Patent Application

**Commissioner for Patents** P.O. Box 1450 Alexandria, VA 22313-1450

Certificate of Transmission under 37 CFR 1.8 I hereby certify that this correspondence is being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 CFR 1.10 addressed to the Commissioner for Patents, Alexandria, VA 22313-1450, on the date indicated below;

"Express Mail" label no. EU40976736US

Date

N. Rhys Merrett

## INFORMATION DISCLOSURE STATEMENT

Sir:

This Information Disclosure Statement is submitted under 37 CFR 1.97(b); no fee is required.

Applicants submit herewith Form PTO-1449 - Information Disclosure Citation which applicants believe may be material to the examination of this application and for which there may be a duty to disclose in accordance with 37 CFR 1.56. Copies of the listed information are not provided because they have been previously submitted to, or cited by, the Patent and Trdae Mark Office in one or more of Application No. 08/722,532 filed September 27, 1996, Application No. 09/316,916 filed May 20, 1999, and Application No. 09/735,566 filed December 12, 2000, all relied on for an earlier effective filing date under 37 CFR 120.

It is requested that the information disclosed herein be made of record in this application.

Date: October 1, 2003 **Hewlett-Packard Company Intellectual Property Administration** 

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Fort Collins, CO 80528-9599

Respectfully submitted,

N. Rhvs Merrett Attorney for Applicant Reg. No. 27,250

## PATENT APPLICATION

Sheet 1 of 1\_

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## PATENT APPLICATION

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